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Attorney Docket No.: SP01-193

1731

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventor: Ball, et al.

Serial No: 09/920227

Filing Date: 8/1/2001

Title: METHOD FOR MAKING
PHOTOMASK MATERIAL BY
PLASMA INDUCTION

Commissioner of Patents
Alexandria, VA 22313-1450

) Art Group Unit: 1731

) Examiner: Sean E. Vincent

) I hereby certify that this paper (along with any paper
) referred to as being attached or enclosed) is being dep
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) 1450, Alexandria, VA 22313-1450, on:

February 23, 2004
Date

Colleen E. Doherty
Signature: Colleen E. Doherty

REQUEST FOR EXTENSION OF TIME TO RESPOND TO OFFICIAL ACTION

Applicants, through counsel, respectfully request a one (1) month extension of time pursuant to 37 C.F.R. § 1.136(a), or such other extension of time as is necessary, to respond to the Office Action dated October 21, 2003 currently due. Please charge the fee of \$ 110.00, and any additional fees or surcharges necessary to make this response timely, to the deposit account of the undersigned corporation, **Deposit Account No. 03-3325**, and credit any overpayment.

The undersigned attorney is granted limited recognition by the Office of Discipline and Enrollment of the USPTO to practice before the USPTO in capacity as an employee of Corning Incorporated. A copy of the document granting such limited recognition either has been previously submitted or is submitted herewith for the record.

Please direct any questions or comments to the undersigned at (607) 248-1253.

Date: February 23, 2004

Respectfully submitted,

Siwen Chen
Attorney/Agent for Assignee
Siwen Chen
Corning Incorporated
SP-TI-3-1
Corning, NY 14831
607-248-1253

03/04/2004 EAREGAY1 00000101 033325 09920227
01 FC:1251 110.00 DA

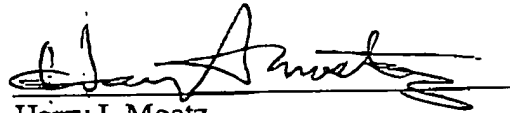
**BEFORE THE OFFICE OF ENROLLMENT AND DISCIPLINE
UNITED STATES PATENT AND TRADEMARK OFFICE**

LIMITED RECOGNITION UNDER 37 CFR § 10.9(b)

Siwen Chen is hereby given limited recognition under 37 CFR § 10.9(b), as an employee of Corning Incorporated to prepare and prosecute patent applications in which (i) Corning Incorporated is the assignee of all right, title and interest in the invention claimed in the application; (ii) a wholly-owned subsidiary of Corning Incorporated is the assignee of all right, title and interest in the invention claimed in the application; or (iii) a joint venture of Corning Incorporated is the assignee of all right, title and interest in the invention claimed in the application. This limited recognition shall expire on the date appearing below, or when whichever of the following events first occurs prior to the date appearing below: (i) Siwen Chen ceases to lawfully reside in the United States, (ii) Siwen Chen's employment with Corning Incorporated ceases or is terminated, or (iii) Siwen Chen ceases to remain or reside in the United States on an H-1 visa.

This document constitutes proof of such recognition. The original of this document is on file in the Office of Enrollment and Discipline of the U.S. Patent and Trademark Office.

Expires: July 11, 2004



Harry I. Moatz

Director of Enrollment and Discipline